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11w/2814



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of
HORNING et al.

Serial Number:
09/873,931

Filed: June 4, 2001

For:
APPLICATIONS OF A
STRAIN-COMPENSATED
HEAVILY DOPED ETCH STOP
FOR SILICON STRUCTURE
FORMATION

Group Art Unit:
2814

Examiner:
Steven H. Rao

Docket No. H25542US

To the Commissioner of Patents and Trademarks:

Sir:

AMENDMENT

Please enter the following amendments in response to the Office Action mailed July 8, 2005.